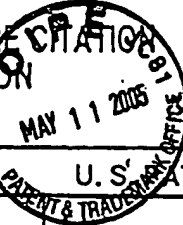


INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)



Docket Number (Optional)

DS-03-028

Application Number

10/830,157

Applicant

Andreas Sibrai

Filing Date

04/22/04

Group Art Unit

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ath	5459449	10/17/95	Rivas, Jr. et al.	340	438	3/10/94
	5675242	10/7/97	Nakano	323	312	7/1/96
	2874956	2/24/59	La Belle	267	18	12/20/54
↓	5194755	3/16/93	Rhee et al.	307	10.1	3/4/91

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
ath	DE 101 47884 A	4/24/03	Germany	B60R	21/01		
↓	WO 02 / 26529 A	4/4/02	Int'l Patent	B60R	21/01		

OTHER DOCUMENTS (Including Author, Title, Date, Portinart Pages, Etc.)

ath	-	U.S. Patent App. Pub. US 2002/0050826 A1 to Boran et al. Pub. Date 05/02/02, Filed 10/31/01, U.S. Cl. 324/525.
	-	U.S. Patent App. Pub. US 2001/009337 A1 to Ueno et al., Pub. Date 07/26/01, Filed 01/24/01, U.S. Cl. 307/10.1.
↓	-	U.S. Patent App. Pub. US 2001/0006309 A1 to Ueno et al., Pub. Date 07/05/01, Filed 12/22/00, U.S. Cl. 307/10.1.

EXAMINER

DATE CONSIDERED

2/14/06

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DS-03-028

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Andreas Sibra:

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attch	-	U.S. Patent App. Publication US 2001/0006309 A1, to Ueno et al., Pub. Date 07/05/01, US Class 307/10. filed 12/22/00.

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2/14/06

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